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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	VENTOR ATTORNEY DOCKET NO.			
10/567,809	04/25/2008	Shunichi Sato	2271/75845	6291		
23432 COOPER & DU	7590 04/21/200 J NHAM, LLP	EXAMINER				
30 Rockefeller 20th Floor		PARK, KINAM				
NEW YORK, N	NY 10112		ART UNIT	PAPER NUMBER		
			2828			
			MAIL DATE	DELIVERY MODE		
			04/21/2009	PAPER		

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Ą	Application No.		Applicant(s)			
		10	0/567,809	:	SATO ET AL.			
Office Action Summary			caminer	1	Art Unit	T		
		кі	NAM PARK		2828			
Period fo	The MAILING DATE of this commun or Reply	nication appear	s on the cover she	eet with the co	rrespondence a	ddress		
A SH WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR CHEVER IS LONGER, FROM THE Masions of time may be available under the provision SIX (6) MONTHS from the mailing date of this composition of period for reply is specified above, the maximum is to reply within the set or extended period for reply reply received by the Office later than three months and patent term adjustment. See 37 CFR 1.704(b).	MAILING DATE s of 37 CFR 1.136(a) munication. tatutory period will ap y will, by statute, caus	OF THIS COMM. In no event, however, reply and will expire SIX (6 se the application to become	MUNICATION. may a reply be timel b) MONTHS from the bome ABANDONED	y filed e mailing date of this (35 U.S.C. § 133).			
Status								
1) 又	Responsive to communication(s) fil	ed on 20 Febru	iany 2000					
2a)□	Responsive to communication(s) filed on <u>20 February 2009</u> . This action is FINAL . 2b)⊠ This action is non-final.							
3)		<i>7</i> —		matters pros	ecution as to th	e merits is		
<u>ا</u>	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	on of Claims							
4)⊠	Claim(s) <u>1-10</u> is/are pending in the	application						
	4a) Of the above claim(s) is/are withdrawn from consideration.							
	Claim(s) is/are allowed.							
′—	Claim(s) is/are allowed. Claim(s) <u>1-3</u> is/are rejected.							
·	Claim(s) <u>4-10</u> is/are objected to.							
	Claim(s) are subject to restri	ction and/or ele	ection requiremen	nt.				
Applicat	on Papers							
	The specification is objected to by the	o Evaminor						
, —			VM accepted or b	a)□ objected	to by the Evam	inor		
10)☑ The drawing(s) filed on <u>07 February 2006</u> is/are: a)☑ accepted or b)☐ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
				-		`ED 1 121/d\		
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
,—	•	o by the Exami	ner. Note the atte		iction of lonn i	10-102.		
	ınder 35 U.S.C. § 119							
	Acknowledgment is made of a claim	for foreign prid	ority under 35 U.S	S.C. § 119(a)-(d) or (f).			
a)	All b) Some * c) None of:							
	1. Certified copies of the priority documents have been received.							
	2. Certified copies of the priority documents have been received in Application No							
	3. Copies of the certified copies of the priority documents have been received in this National Stage							
	application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.								
Attachmen	t(s)							
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)								
2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date 3) ☑ Information Disclosure Statement(s) (PTO/SB/08) 5) ☐ Notice of Informal Patent Application								
	nation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date <u>2/7/2006</u> .		· —	er:	от пррпосион			

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DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of claims 1-10 in the reply filed on February
 20, 2009 is acknowledged.

- 2. Claims 11-35 are cancelled from further consideration pursuant to 37 CFR
- 1.142(b) as being drawn to a nonelected species, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on February 20, 2009.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by Liu (Pub No. 20040091011).

Regarding claim 1,

Liu discloses in figure 149 and specification:

- 1. (original) A surface-emission laser diode, characterized by:
- a semiconductor substrate (p-GaAs substrate);
- a cavity region formed over said semiconductor substrate(p-GaAs substrate), said cavity region comprising: an active layer structural part (GaInNAs/ GaAs MQW)

including at least one quantum well active layer (GaInNAs, in GaInNAs/ GaAs MQW) producing a laser light and a barrier Layer (GaAs, in GaInNAs/ GaAs MQW); and a spacer layer (GaAs cavity spacer layer) provided in a vicinity of said active layer structural part, said spacer layer comprising at least one material (GaAs); and

an upper reflector (n- Al_{0.8}Ga_{0.2}As /GaAs DBR) and a lower reflector (p- Al_{0.8}Ga_{0.2}As /GaAs DBR) provided over said semiconductor substrate respectively at a top part and a bottom part of said cavity region,

said cavity region, said upper reflector (n- Al_{0.8}Ga_{0.2}As /GaAs DBR) and said lower reflector (p- Al_{0.8}Ga_{0.2}As /GaAs DBR) forming a mesa structure (see, figure 149) over said semiconductor substrate,

said upper reflector (n- Al_{0.8}Ga_{0.2}As /GaAs DBR) and said lower reflector (p- Al_{0.8}Ga_{0.2}As /GaAs DBR) constituting a semiconductor distributed Bragg reflector having a periodic change of .refractive index and reflecting an incident light by interference of optical waves,

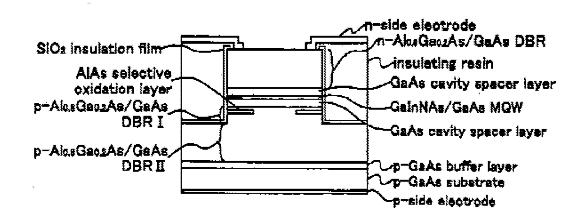
at least a part of said semiconductor distributed Bragg reflector being formed of a layer of small refractive index of $Al_xGa_{1-x}As$ (0<x≤1) and a layer of large refractive index of $Al_xGa_{1-x}As$ (0≤y<x≤1) (see, paragraph [1200]),

said lower reflector being formed of a first lower reflector having a low-refractive index layer of AlAs and a second lower reflector formed on said first lower reflector, said second lower reflector having a low-refractive index, layer of AlGaAs (see, paragraph [1129], see, also, figure 138),

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wherein ant one constituting said cavity region contains In (see, GaInNAs/ GaAs MQW)

FIG.149



Regarding claims 2-3,

Note that Liu discloses in figure 149 and specification at least, a lower spacer layer and an upper spacer layer contains In (see, paragraph [0456], here, GaInPAs) (claim 2), said second lower reflector, said low refractive index layer and said high refractive index layer are repeated by 10 pairs or less (see, paragraph [1199], here, Bragger reflector I (region I))(claim 3).

Allowable Subject Matter

5. Claims 4-10 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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Conclusion

6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Ramdani et al. (US 5633886) discloses the short wavelength VCSEL with Al-free active region.

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kinam Park whose telephone number is (571) 270-1738. The examiner can normally be reached on from 9:00 AM-5:00 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, MINSUN HARVEY, can be reached on (571) 272-1835. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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/K. P./

Examiner, Art Unit 2828

/Minsun Harvey/ Supervisory Patent Examiner, Art Unit 2828